

Thanks to members!

This is the second English journal on electronics packaging and its related issues. Last year, the Japan Institute of Electronics Packaging (JIEP) decided to publish the English journal in order to provide information on Jisso technology including assembling, packaging, mounting and interconnection, and to share new ideas for developing future devices with engineers and scientists worldwide. The JIEP welcomes all the contributions to the journal from engineers and scientists. Last year, the first journal published 10 papers and the second journal has published 25 papers. Professor Hajime Tomokage, the first editor-in-chief of this journal said "We believe that the level of semiconductor assembling and packaging technology in Japan has been high so far, but we Japanese are not good at making English presentations to overseas engineers. We have noticed that it is important for Japanese to send technical information on Jisso to the world over. The JIEP certainly welcomes the submission of exciting papers from overseas countries. We hope that we can stimulate each other by sharing the state-ofthe-art ideas and technology through this journal." The increase of submitted papers proves the realization of Prof. Tomokage's hope. Moreover, this journal has accepted 5 papers which were submitted from overseas. I hope the third journal will publish even more such papers. I would like to thank all the editors who worked hard on this second publication. Finally, I would also like to thank the JIEP members for submitting papers, especially the committee of the International Conference on Electronics Packaging 2009 (ICEP 2009), and I look forward to the support of ICEP 2010.

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